



7/11/04
AFS

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q80136

Yoshitaka MIYAKE

Appln. No.: 10/790,124

Group Art Unit: 1713

Confirmation No.: 1136

Examiner: Bernard Lipman

Filed: March 2, 2004

For: POLYVINYL ACETAL RESIN FOR HEAT-DEVELOPABLE PHOTSENSITIVE MATERIAL AND HEAT-DEVELOPABLE PHOTSENSITIVE MATERIAL

NOTICE OF APPEAL

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Applicant hereby appeals to the Board of Patent Appeals and Interferences from the final Office Action dated November 10, 2005.

The USPTO is directed and authorized to charge the statutory fee of \$500.00 to Deposit Account No. 19-4880. Please also credit any overpayments to said Deposit Account. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

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WASHINGTON OFFICE

23373

CUSTOMER NUMBER

Date: May 10, 2006

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